AMENDMENTS TO THE CLAIMS

Please amend claims 1, 3 through 5, 22 through 26, 29, 30, 45 and 46 such that the claims of the application have the following formulations and statuses:

- 1. (Currently amended) A ferromagnetic thin-film material based digital memory, said memory comprising:
 - a plurality of bit structures, each supported on a substrate and separated from one another by spacer material therebetween, and that are electrically interconnected with information retrieval circuitry, said bit structures each comprising a ferromagnetic magnetic material film in which its ferromagnetic a characteristic magnetic property is substantially maintained below a critical temperature above which such ferromagnetic magnetic property is not maintained, said bit structures each having a first interconnection structure providing electrical contact thereto positioned against at least one side thereof; and
 - a plurality of word line structures each having a pair of word line end terminal regions adapted to conduct electrical current in at least one direction therethrough, each of said pairs of word line end terminal regions having an electrical conductor electrically connected therebetween with each said electrical conductor having a plurality of heat dissipation structures connected thereto that are each located across said spacer material from said first and second ferromagnetic magnetic material films film in a corresponding one of said bit structures and exhibiting sufficient electrical resistance therein for a sufficient electrical current therethrough to cause substantial heating of said bit structure corresponding thereto to raise temperatures thereof to have said ferromagnetic magnetic material film therein at least approach said critical temperature while being substantially

-3-

above temperatures of at least an adjacent said bit structure because of sufficient extents of, and smallness of thermal conductivities of, said first interconnection structure positioned against said corresponding bit structure and of those portions of said substrate and said spacer material positioned thereabout, said plurality of heat dissipating structures each having a location thereon spaced apart from where connected to a said electrical conductor that is selectively connectable so as to be capable of allowing electrical current to be established in that heat dissipating structure.

- The device of claim 1 wherein said selected bit structure is electrically interconnected 2. (Original) so that an electrical current is also establishable therethrough during said heating thereof so as to cause its temperature to more closely approach or exceed said critical temperature of said magnetic material film therein.
- The device of claim 1 wherein said magnetic material film is [[a]] 3. (Currently amended) memory film of an anisotropic ferromagnetic material.
- The device of claim 1 wherein said magnetic material film is a 4. (Currently amended) magnetization direction maintaining film of an antiferromagnetic material, and said bit structures further comprise [[a]] memory film of an anisotropic ferromagnetic material positioned adjacent to said magnetic material film.
- The device of claim 1 wherein said magnetic material film is a 5. (Currently amended) magnetization direction maintaining composite film including an antiferromagnetic material, and said bit structures further comprise [[a]] memory film of an anisotropic ferromagnetic material positioned adjacent to said magnetic material film.

-4-

6. (Original) The device of claim 1 wherein said first interconnection structure extends to an adjacent one of said plurality of bit structures to make electrical contact thereto.

7. (Original) The device of claim 1 wherein said substrate comprises an electrical insulating layer over a monolithic integrated circuit, and further comprises via interconnection structures each providing electrical contact to a corresponding one of said plurality of bit structures where positioned against at least one other side thereof through said insulating layer to a corresponding circuit portion in said monolithic integrated circuit.

8. (Original) The device of claim 2 wherein another said bit structure in said plurality thereof is electrically connected in series with said selected bit structure so that any said electrical current established through said selected bit structure during said heating thereof is also established through said other bit structure but is insufficient to heat that said other bit structure to substantially approach said critical temperature thereof, a said electrical current being establishable through said selected bit structure and a said electrical current being establishable through that said heat dissipating structure across from said selected bit structure to cause together sufficient heating of said selected bit structure to allow that magnetization of a memory film of an anisotropic ferromagnetic material provided therein to be positioned in a selected direction by at least some portion of such electrical currents in less time than that maximum data storage time period allowed in that digital memory in which said selected bit structure is provided.

9. (Original) The device of claim 3 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces of thicknesses differing from one another outwardly from those surfaces by at least 5% to thereby primarily provide switching thresholds below said critical temperature for magnetizations of said film adjacent each of said intermediate layer major surfaces that differ in value for a switching of these magnetizations from

-5-

First Named Inventor: James M. Daughton

both being directed initially at least in part in substantially a common direction to being directed at least in part in substantially opposite directions versus a switching from being directed initially at least in part in substantially opposite directions to both being directed at least in part in substantially a common direction.

- 10. (Original) The device of claim 3 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces.
- 11. (Original) The device of claim 4 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces.
- 12. (Original) The device of claim 4 wherein said magnetization direction maintaining film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is less than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 13. (Original) The device of claim 4 wherein said magnetization direction maintaining film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 14. (Original) The device of claim 5 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces.

- 15. (Original) The device of claim 5 wherein said magnetization direction maintaining composite film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is less than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 16. (Original) The device of claim 5 wherein said magnetization direction maintaining composite film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 17. (Original) The device of claim 5 wherein said magnetization direction maintaining composite film including an antiferromagnetic material further includes two holding ferromagnetic layers separated by a ruthenium layer with said antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 18. (Original) The device of claim 8 wherein said maximum data storage time period of said digital memory is less than 100 ns.
- 19. (Original) The device of claim 10 wherein a said bit structure has a length along a selected direction and a width substantially perpendicular thereto that is smaller in extent than said length and has a shaped end portion extending over a portion of said length in which said width gradually reduces to zero at an end thereof.
- 20. (Original) The device of claim 11 wherein a said bit structure has a length along a selected direction and a width substantially perpendicular thereto that is smaller in extent than said length and

has a shaped end portion extending over a portion of said length in which said width gradually reduces to zero at an end thereof.

- 21. (Original) The device of claim 14 wherein a said bit structure has a length along a selected direction and a width substantially perpendicular thereto that is smaller in extent than said length and has a shaped end portion extending over a portion of said length in which said width gradually reduces to zero at an end thereof.
- 22. (Currently amended and withdrawn) A ferromagnetic thin-film material based digital memory, said memory comprising:
 - a plurality of bit structures, each supported on a substrate and separated from one another by spacer material therebetween, and that are electrically interconnected with information retrieval circuitry, said bit structures each comprising a first ferromagnetic magnetic material film in which its ferromagnetic a characteristic magnetic property is substantially maintained below a first critical temperature above which such ferromagnetic magnetic property is not maintained, and further comprising a second ferromagnetic material film such that said second ferromagnetic material film is separated from said first ferromagnetic magnetic material film by at least a layer of nonmagnetic material, said bit structures each having a first interconnection structure providing electrical contact thereto positioned against at least one side thereof; and
 - a plurality of word line structures each having a pair of word line end terminal regions adapted to conduct electrical current in at least one direction therethrough, each of said pairs of word line end terminal regions having an electrical conductor electrically connected therebetween which is located across said spacer material from said first and second ferromagnetic magnetic

-8-

material films in a corresponding one of said bit structures and exhibiting sufficient electrical resistance there for a sufficient electrical current therethrough to cause substantial heating of a selected said corresponding bit structure, a pair of said word line structures each having said electrical conductor thereof positioned on opposite sides of a said bit structure corresponding thereto so as to have said bit structure common to each and with these said electrical conductors extending in different directions so that a sufficient electrical current through each causes substantial heating of said common corresponding bit structure to raise temperatures thereof to have said first ferromagnetie magnetic material film therein at least approach said first temperature while being substantially above temperatures of at least an adjacent said bit structure because of sufficient extents of, and smallness of thermal conductivities of, said first interconnection structure positioned against said selected bit structure and of those portions of said substrate and said spacer material positioned thereabout.

- The device of claim 22 wherein said selected bit 23. (Currently amended and withdrawn) structure is electrically interconnected so that an electrical current is also establishable therethrough during said heating thereof so as to cause its temperature to more closely approach or exceed said critical temperature of said first magnetic material film therein.
- The device of claim 22 wherein said first magnetic 24. (Currently amended and withdrawn) material film is [[a]] memory film of an anisotropic ferromagnetic material.
- The device of claim 22 wherein said first magnetic 25. (Currently amended and withdrawn) material film is a magnetization direction maintaining film of an antiferromagnetic material, and said

bit structures further comprise [[a]] memory film of an anisotropic ferromagnetic material positioned adjacent to said magnetic material film.

- 26. (Currently amended and withdrawn) The device of claim 22 wherein said <u>first</u> magnetic material film is a magnetization direction maintaining composite film including an antiferromagnetic material, and said bit structures further comprise [[a]] memory film of an anisotropic ferromagnetic material positioned adjacent to said magnetic material film.
- 27. (Withdrawn) The device of claim 22 wherein said first interconnection structure extends to an adjacent one of said plurality of bit structures to make electrical contact thereto.
- 28. (Withdrawn) The device of claim 22 wherein said substrate comprises an electrical insulating layer over a monolithic integrated circuit, and further comprises via interconnection structures each providing electrical contact to a corresponding one of said plurality of bit structures where positioned against at least one other side thereof through said insulating layer to a corresponding circuit portion in said monolithic integrated circuit.
- 29. (Currently amended and withdrawn) The device of claim 23 wherein another said bit structure in said plurality thereof is electrically connected in series with said selected bit structure so that any said electrical current established through said selected bit structure during said heating thereof is also established through said other bit structure but is insufficient to heat that said other bit structure to substantially approach said critical temperature thereof, a said electrical current being establishable through said selected bit structure and a said electrical current being establishable through that said heat dissipating structure across from said selected bit structure to cause together sufficient heating of said selected bit structure to allow that magnetization of [[a]] memory film of an anisotropic ferromagnetic material provided therein to be positioned in a selected direction by at

least some portion of such electrical currents in less time than that maximum data storage time period allowed in that digital memory in which said selected bit structure is provided.

- 30. (Currently amended and withdrawn) The device of claim 24 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces of thicknesses differing from one another outwardly from those surfaces by at least 5% to thereby primarily provide switching thresholds below said critical temperature for magnetizations of said memory film adjacent each of said intermediate layer major surfaces that differ in value for a switching of these magnetizations from both being directed initially at least in part in substantially a common direction to being directed at least in part in substantially opposite directions versus a switching from being directed initially at least in part in substantially opposite directions to both being directed at least in part in substantially a common direction.
- 31. (Withdrawn) The device of claim 24 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces.
- 32. (Withdrawn) The device of claim 25 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces.
- 33. (Withdrawn) The device of claim 25 wherein said magnetization direction maintaining film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is less than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.

-11-

34. (Withdrawn) The device of claim 25 wherein said magnetization direction maintaining film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.

- 35. (Withdrawn) The device of claim 26 wherein said plurality of bit structures each further comprises an electrically insulative intermediate layer having two major surfaces on opposite sides thereof with said memory film on each of said intermediate layer major surfaces.
- 36. (Withdrawn) The device of claim 26 wherein said magnetization direction maintaining composite film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is less than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 37. (Withdrawn) The device of claim 26 wherein said magnetization direction maintaining composite film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 38. (Withdrawn) The device of claim 26 wherein said magnetization direction maintaining composite film including an antiferromagnetic material further includes two holding ferromagnetic layers separated by a ruthenium layer with said antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said adjacent memory film.
- 39. (Withdrawn) The device of claim 29 wherein said maximum data storage time period of said digital memory is less than 100 ns.

-12-

40. (Withdrawn) The device of claim 31 wherein a said bit structure has a length along a selected direction and a width substantially perpendicular thereto that is smaller in extent than said length and has a shaped end portion extending over a portion of said length in which said width gradually reduces to zero at an end thereof.

- 41. (Withdrawn) The device of claim 32 wherein a said bit structure has a length along a selected direction and a width substantially perpendicular thereto that is smaller in extent than said length and has a shaped end portion extending over a portion of said length in which said width gradually reduces to zero at an end thereof.
- 42. (Withdrawn) The device of claim 35 wherein a said bit structure has a length along a selected direction and a width substantially perpendicular thereto that is smaller in extent than said length and has a shaped end portion extending over a portion of said length in which said width gradually reduces to zero at an end thereof.
- 43. (Withdrawn) A ferromagnetic thin-film material based digital memory, said memory comprising:
 - a plurality of bit structures, each supported on a substrate and separated from one another by spacer material therebetween, and that are electrically interconnected with information retrieval circuitry, said bit structures each comprising a ferromagnetic material layer, and further comprising a magnetization reference layer having therein an antiferromagnetic material and a layer of electrically insulative material having a pair of major surfaces on opposite sides thereof each against a corresponding one of said ferromagnetic material and magnetization reference layers to thereby separate them from one another with said magnetization reference layer having a

-13-

major surface adjacent to said substrate on a side thereof opposite said electrically insulative material layer; and

first and second interconnection structure contacts positioned against said magnetization reference layer major surface spaced apart from one another.

- 44. (Withdrawn) The device of claim 43 wherein said ferromagnetic material layer is a of an anisotropic ferromagnetic material against which is positioned a third interconnection structure contact.
- 45. (Currently amended and withdrawn) The device of claim 43 wherein said ferromagnetic material layer has [[its]] a characteristic ferromagnetic property substantially maintained below a first critical temperature above which such ferromagnetic property is not maintained.
- 46. (Currently amended and withdrawn) The device of claim 43 wherein said magnetization direction maintaining layer has [[its]] a characteristic antiferromagnetic property substantially maintained below a first critical temperature above which such ferromagnetic antiferromagnetic property is not maintained.
- 47. (Withdrawn) The device of claim 43 wherein said substrate comprises an electrical insulating layer over a monolithic integrated circuit, and further comprises via interconnection structures each providing one of first and second interconnection structure contacts to a corresponding one of said plurality of bit structures where positioned against at least one side thereof through said insulating layer to a corresponding circuit portion in said monolithic integrated circuit.
- 48. (Withdrawn) A method for storing information in a plurality of bit structures electrically interconnected with information retrieval circuitry that are in a ferromagnetic thin-film based digital memory each comprising a magnetic material film in which a characteristic magnetic property is

. 1

-14-

maintained below a critical temperature above which such magnetic property is not maintained, said method comprising:

establishing electrical current in a selected direction through a selected bit structure sufficient to cause said magnetic material film therein to heat sufficiently to approach said critical temperature thereof; and

reducing said electrical current in magnitude sufficiently to allow said magnetic material film to cool while generating a magnetic field based on said electrical current about said magnetic material film during such cooling.

49. (Withdrawn) The device of claim 48 wherein said maximum data storage time period of said digital memory is less than 100 ns.

50. (Withdrawn) The device of claim 48 wherein said substrate comprises an electrical insulating layer over a monolithic integrated circuit, and further comprises via interconnection structures each providing electrical contact to a corresponding one of said plurality of bit structures where positioned against at least one side thereof through said insulating layer to a corresponding circuit portion in said monolithic integrated circuit.

51. (Withdrawn) A ferromagnetic thin-film material based digital memory, said memory comprising:

a plurality of bit structures, each supported on a substrate and separated from one another by spacer material therebetween, and that are electrically interconnected with information retrieval circuitry, said bit structures each comprising a first magnetic material film in which a characteristic magnetic property is substantially maintained below a first critical temperature above which such magnetic property is not maintained, and further comprising a second magnetic material film in which a characteristic magnetic property is

substantially maintained below a second critical temperature above which such magnetic property is not maintained, and yet further comprising a third magnetic material film in which a characteristic magnetic property is substantially maintained below a third critical temperature above which such magnetic property is not maintained, such that said third magnetic material film is separated from said first and second magnetic material films by at least one layer of a nonmagnetic material, said bit structures each having a first interconnection structure providing electrical contact thereto positioned against at least one side thereof; and

a plurality of word line structures each having a pair of word line end terminal regions adapted to conduct electrical current in at least one direction therethrough, each of said pairs of word line end terminal regions having an electrical conductor electrically connected therebetween which is located across said spacer material from said first, second and third magnetic material films in a corresponding one of said bit structures and exhibiting sufficient electrical resistance there for a sufficient electrical current therethrough to cause substantial heating of a selected said corresponding bit structure to raise temperatures thereof to have said first, second and third magnetic material films therein at least approach that one of said first, second and third critical temperatures of greatest value while being substantially above temperatures of at least an adjacent said bit structure because of sufficient extent of, and smallness of thermal conductivities of, said first interconnection structure positioned against said selected bit structure and of those portions of said substrate and said spacer material positioned thereabout.

- 52. (Withdrawn) The device of claim 51 wherein said selected bit structure is electrically interconnected so that an electrical current is also establishable therethrough during said heating thereof so as to cause its temperature to more closely approach or exceed a said critical temperature of said magnetic material films therein.
- 53. (Withdrawn) The device of claim 51 wherein at least one of said magnetic material films comprises an anisotropic ferromagnetic material.
- 54. (Withdrawn) The device of claim 51 wherein at least one of said magnetic material films comprises an antiferromagnetic material.
- 55. (Withdrawn) The device of claim 51 wherein said first interconnection structure extends to an adjacent one of said plurality of bit structures to make electrical contact thereto.
- 56. (Withdrawn) The device of claim 51 wherein said substrate comprises an electrical insulating layer over a monolithic integrated circuit, and further comprises via interconnection structures each providing electrical contact to a corresponding one of said plurality of bit structures where positioned against at least one side thereof through said insulating layer to a corresponding circuit portion in said monolithic integrated circuit.
- 57. (Withdrawn) The device of claim 51 wherein said first magnetic material film is a magnetization direction maintaining film of an antiferromagnetic material, and said bit structures further comprise a first memory film of an anisotropic ferromagnetic material positioned adjacent to said first magnetic material film.
- 58. (Withdrawn) The device of claim 51 wherein said first magnetic material film is a magnetization direction maintaining composite film including an antiferromagnetic material, and

First Named Inventor: James M. Daughton

-17-

said bit structures further comprise a first memory film of an anisotropic ferromagnetic material positioned adjacent to said first magnetic material film.

- 59. (Withdrawn) The device of claim 57 wherein said magnetization direction maintaining film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is less than that Curie temperature characterizing said anisotropic ferromagnetic material of said first memory film.
- 60. (Withdrawn) The device of claim 57 wherein said magnetization direction maintaining film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said first memory film.
- 61. (Withdrawn) The device of claim 57 wherein said second magnetic material film comprises a second memory film of an anisotropic ferromagnetic material.
- 62. (Withdrawn) The device of claim 57 wherein said third magnetic material film comprises a second memory film of an anisotropic ferromagnetic material.
- 63. (Withdrawn) The device of claim 58 wherein said magnetization direction maintaining composite film is of an antiferromagnetic material having a blocking temperature as its critical temperature that is less than that Curie temperature characterizing said anisotropic ferromagnetic material of said first memory film.
- 64. (Withdrawn) The device of claim 58 wherein said magnetization direction maintaining composite film is of an antiferromagnetic material having a blocking temperature as its critical

First Named Inventor: James M. Daughton

temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said first memory film.

- 65. (Withdrawn) The device of claim 58 wherein said magnetization direction maintaining composite film including an antiferromagnetic material further includes two holding ferromagnetic layers separated by a ruthenium layer with said antiferromagnetic material having a blocking temperature as its critical temperature that is greater than that Curie temperature characterizing said anisotropic ferromagnetic material of said first memory film.
- 66. (Withdrawn) The device of claim 58 wherein said second magnetic material film comprises a second memory film of an anisotropic ferromagnetic material.
- 67. (Withdrawn) The device of claim 58 wherein said third magnetic material film comprises a second memory film of an anisotropic ferromagnetic material.
- 68. (Withdrawn) The device of claim 61 wherein said layer of a nonmagnetic material comprises an electrically insulative material.
- 69. (Withdrawn) The device of claim 61 wherein said layer of a nonmagnetic material comprises an electrically conductive material.
- 70. (Withdrawn) The device of claim 61 wherein said third magnetic material film comprises an anisotropic ferromagnetic material.
- 71. (Withdrawn) The device of claim 66 wherein said layer of a nonmagnetic material comprises an electrically insulative material.

-19-

72. (Withdrawn) The device of claim 66 wherein said layer of a nonmagnetic material comprises an electrically conductive material.

73. (Withdrawn) The device of claim 66 wherein said third magnetic material film comprises an anisotropic ferromagnetic material.